

L Number	Hits	Search Text	DB	Time stamp
1	2	("6330065").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/22 11:33
2	211	(438/7).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/22 11:33
-	5	semiconductor adj wafer and exposure adj apparatus and eximer adj laser and reticle	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/22 11:30
-	756779	vacuum	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 09:48
-	0	(semiconductor adj wafer and exposure adj apparatus and eximer adj laser and reticle) and vacuum	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 09:48
-	10	5227862.URPN.	USPAT	2002/11/21 09:48
-	9955	exposure adj apparatus	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 15:33
-	466569	exposure	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 10:11
-	666	vacuum adj stage	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 09:52
-	109	exposure and (vacuum adj stage)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 09:55
-	1069	eximer adj laser	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 15:34
-	0	(exposure and (vacuum adj stage)) and (eximer adj laser)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 09:53
-	0	(vacuum adj stage) and (eximer adj laser)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 09:56
-	16894	reticle	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 09:57

-	8977	exposure and reticle	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 15:34
-	36	(eximer adj laser) and (exposure and reticle)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 15:24
-	9955	exposure adj apparatus	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 16:50
-	4	(vacuum adj stage) and (exposure adj apparatus)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 10:13
-	2	("5286963").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 12:13
-	27	5286963.URPN.	USPAT	2002/11/21 12:13
-	15	("4655599" "4962423" "5015866" "5137349" "5286963" "5323016" "5361122" "5448332" "5581324" "5635722" "5693439" "5742067" "5751428" "5781277" "5793471").PN.	USPAT	2002/11/21 12:29
-	5	(eximer adj laser) and (exposure and reticle) and (ccd or "charge coupled device")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 15:32
-	10	5227862.URPN.	USPAT	2002/11/21 15:29
-	955470	computer	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 15:33
-	1345	exposure adj apparatus and computer	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 15:33
-	509	exposure and reticle and (exposure adj apparatus and computer)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 15:34
-	3	eximer adj laser and (exposure and reticle and (exposure adj apparatus and computer))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 15:35
-	74	exposure adj apparatus and computer and "local area network"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/21 16:52
-	1	("6451507").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/22 10:00